

PRESS RELEASE

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Micronic receives order for a pattern generator for TFT applications

Täby, Sweden, November 27, 2001 — Micronic Laser Systems AB (Stockholmsbörsen's Attract 40: MICR), a leading supplier of laser pattern generators for semiconductor and display photomasks, today announced that it has received an order from a leading Japanese photomask producer for a single beam pattern generator for TFT and color filter applications.

“We are pleased to see that the continued high utilization within the display segment now also generates capacity investments among our customers. This new order, in line with our expectations, increases Micronic's opportunities to meet the full year outlook,” said Sven Löfquist, president & CEO of Micronic Laser Systems AB.

About Micronic Laser Systems AB

Micronic Laser Systems AB is a Swedish high-tech company engaged in the development, manufacture and marketing of a series of extremely accurate laser pattern generators for the production of photomasks. The technology involved is known as microlithography. Micronic's systems are used by the world's leading electronics companies in the manufacture of television and computer displays, semiconductor circuits and semiconductor packaging components.

Micronic is located in Täby, north of Stockholm and at present has subsidiaries in the United States and Japan and a service office in Taiwan. Micronic's net sales for 2000 amounted to MSEK 704 (MSEK 213 in 1999) and the company has 325 employees. Micronic maintains a web site at: <http://www.micronic.se>